

## **Partial sulfur vacancy created by carbon-nitrogen deposition of MoS<sub>2</sub> for high-performance overall electrocatalytic water splitting**

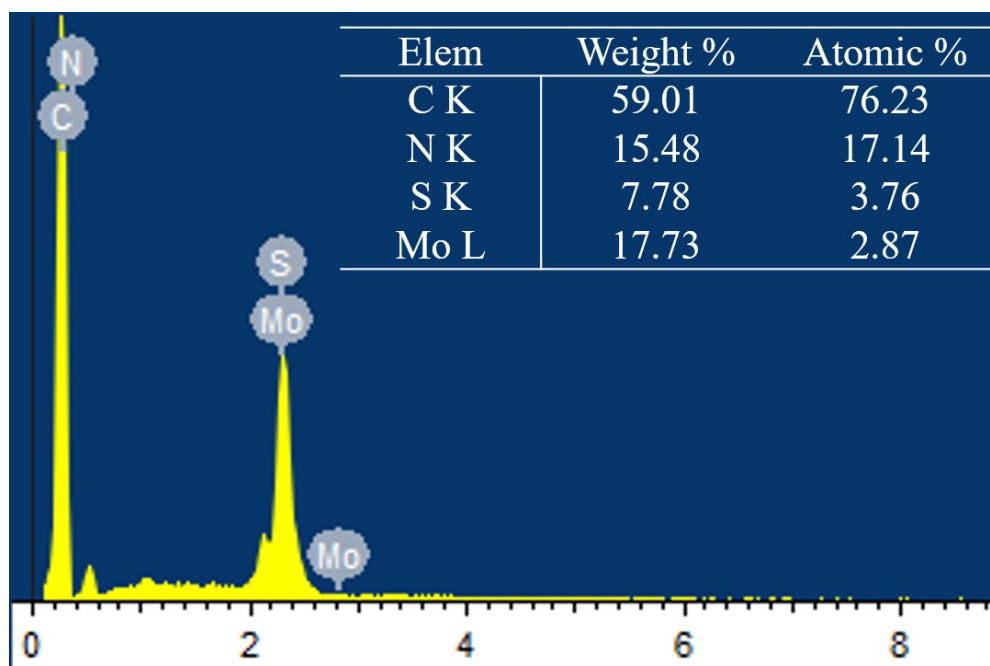
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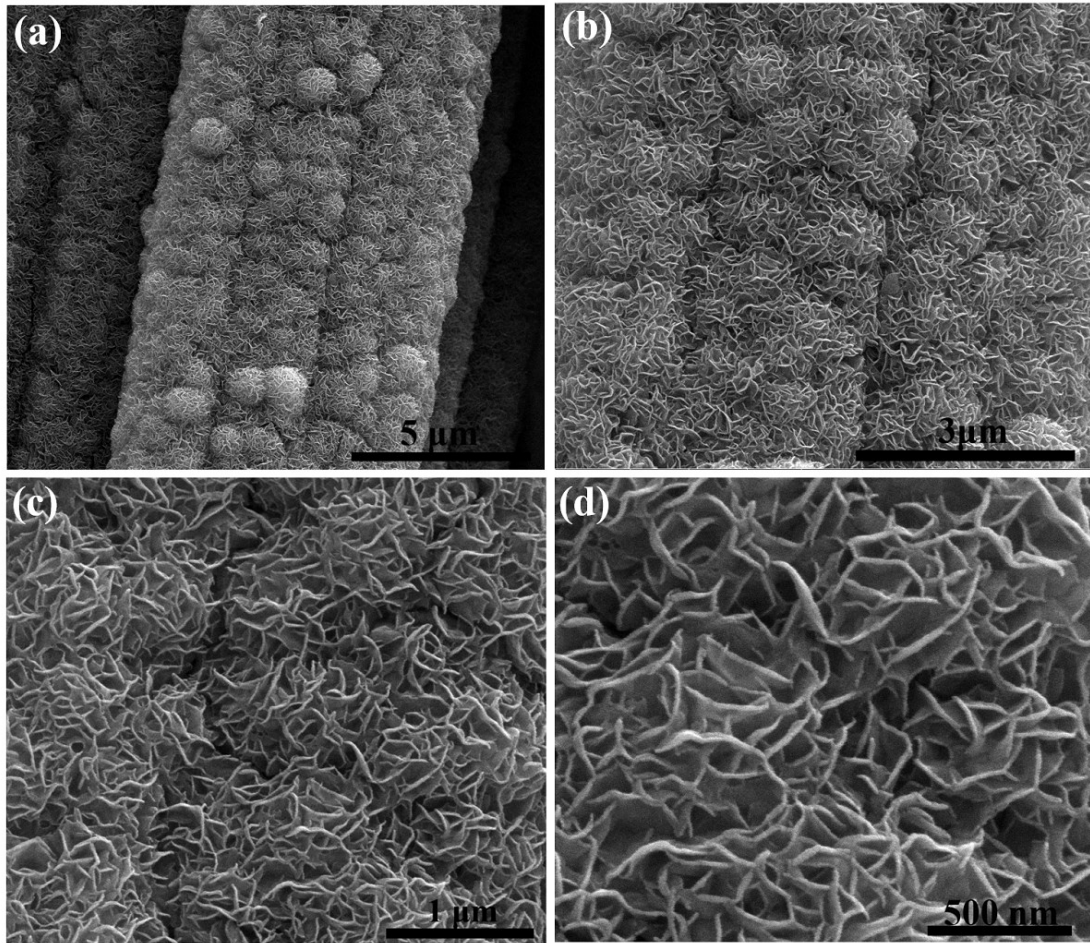
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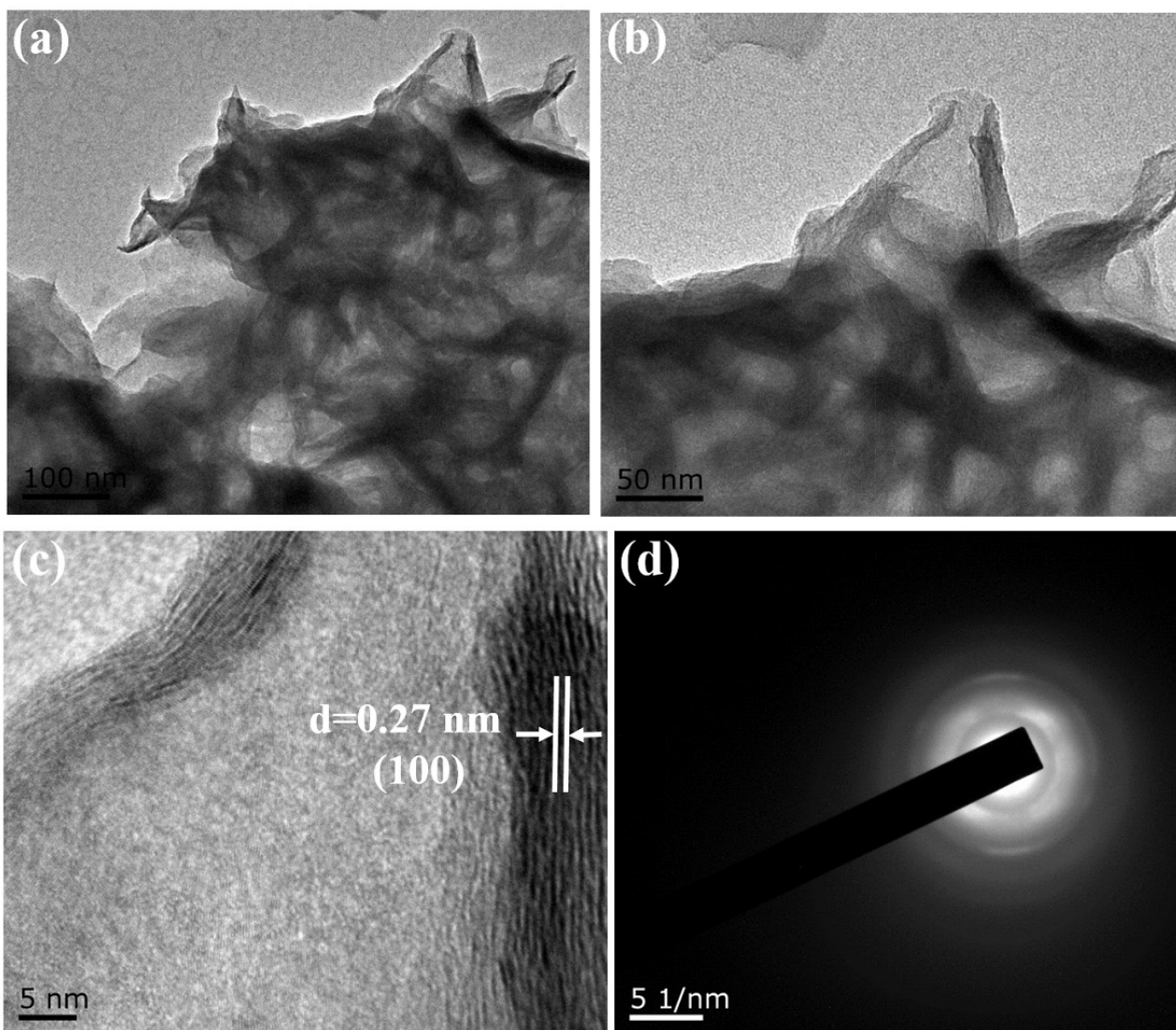
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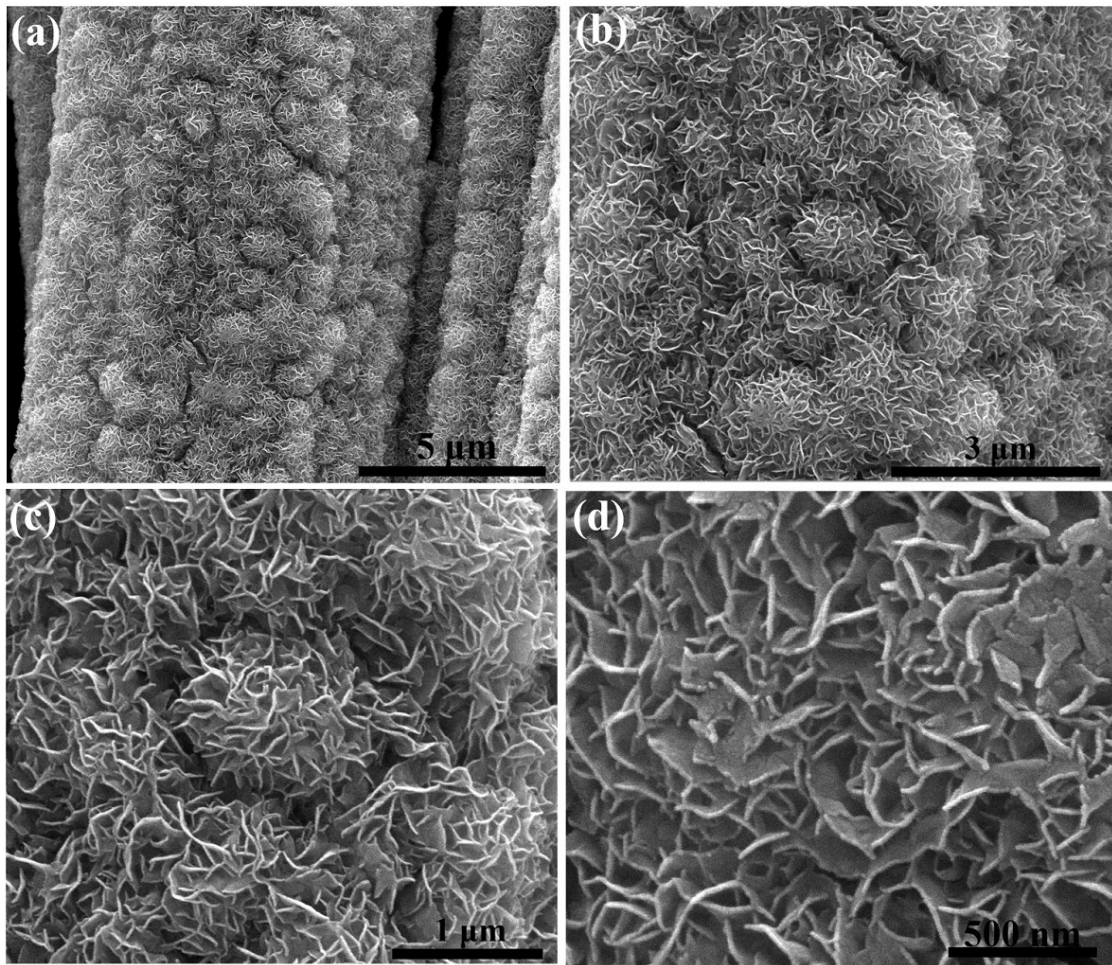
**Fig. S1.** The EDX spectral analysis of the C-N-MoS<sub>2</sub>/CC-700 material.



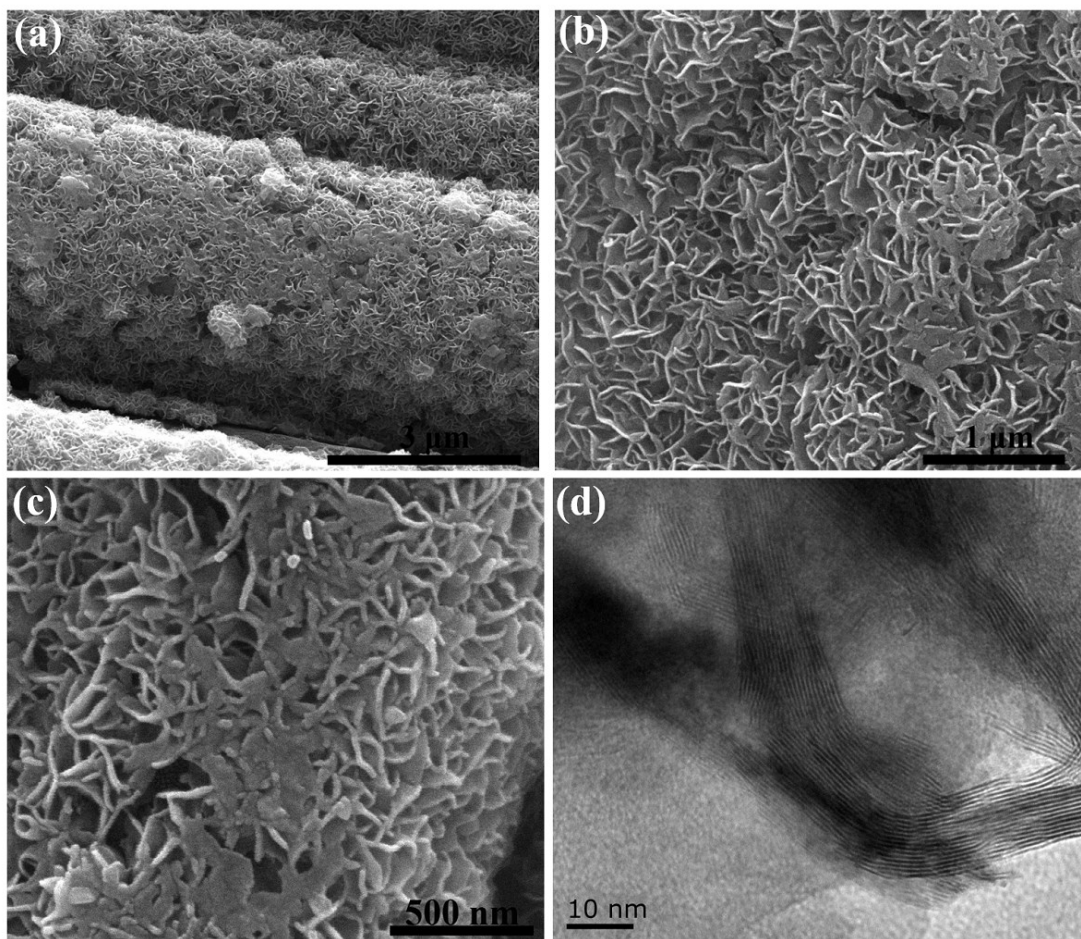
**Fig. S2.** The SEM image of the pure MoS<sub>2</sub>/CC.



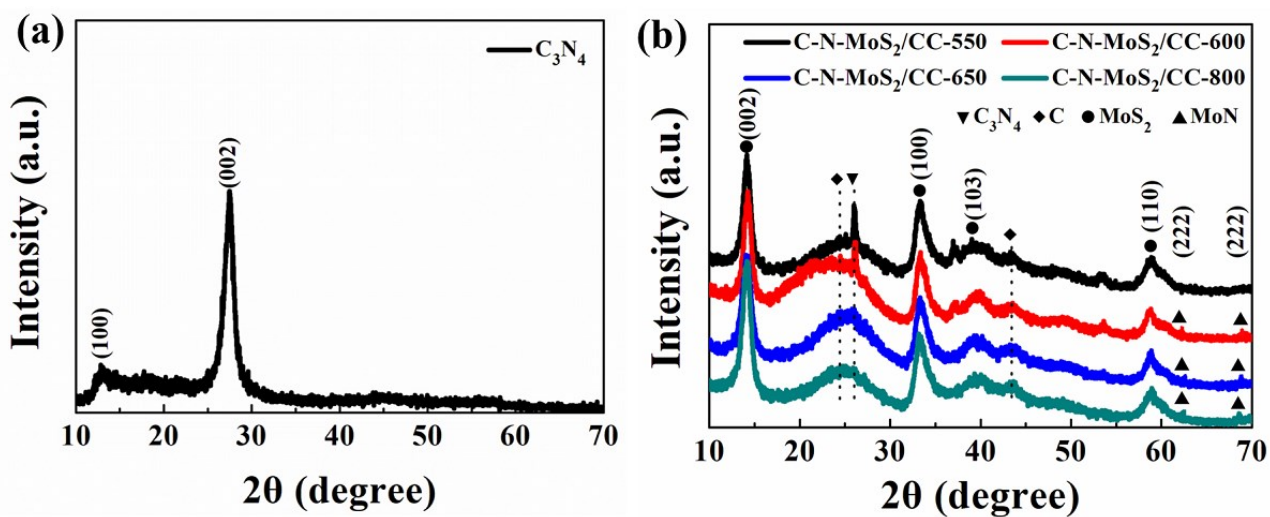
**Fig. S3.** (a) and (b) TEM image, (c) HRTEM image and (d) electron diffraction of the pure MoS<sub>2</sub>/CC.



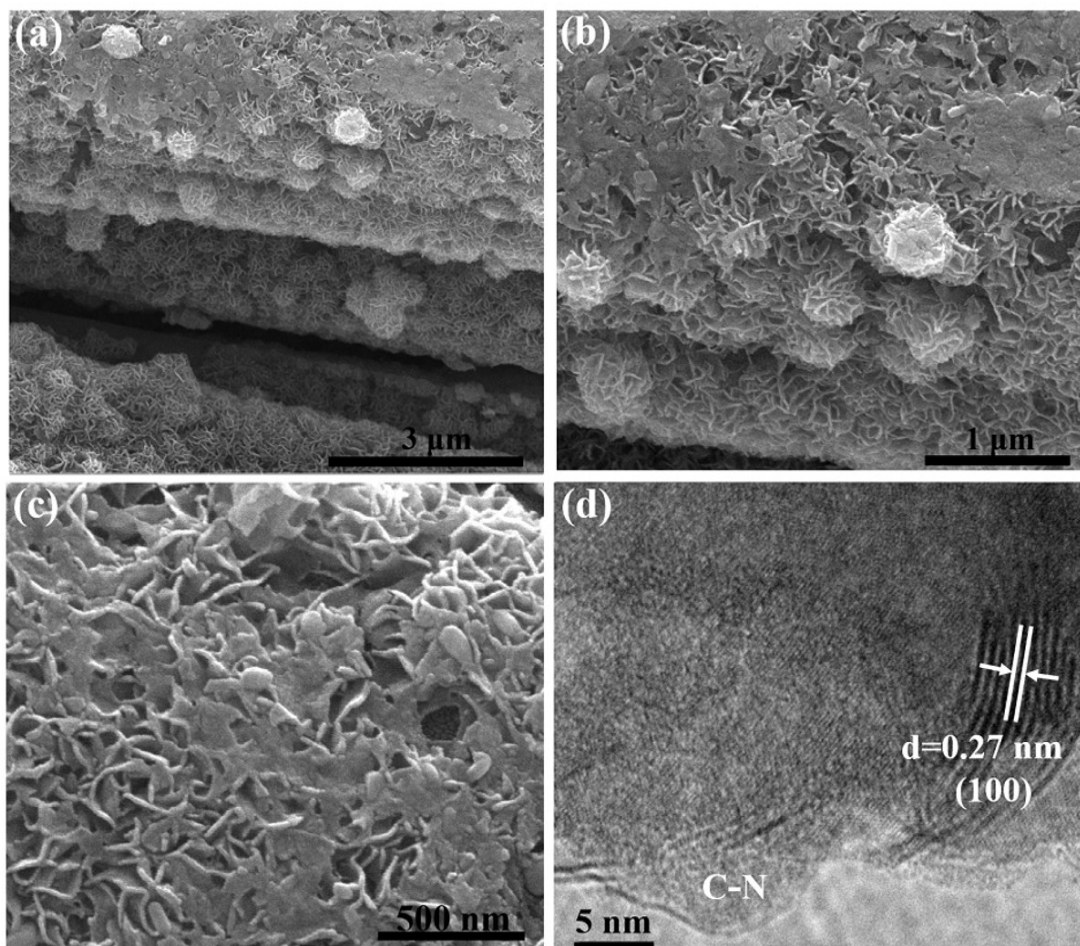
**Fig. S4.** The SEM image of the C-N-MoS<sub>2</sub>/CC-550.



**Fig. S5.** The SEM image of the C-N-MoS<sub>2</sub>/CC-600.

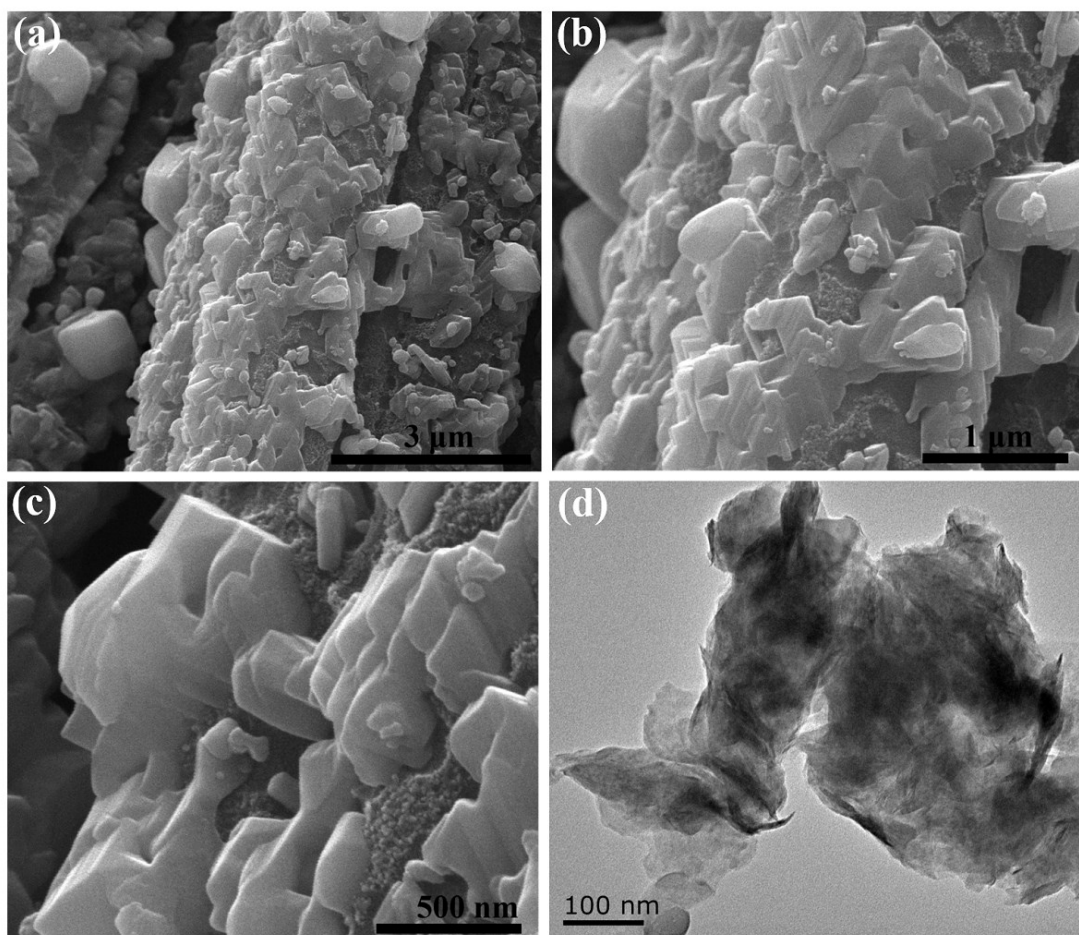


**Fig. S6.** The XRD patterns of the as-prepared catalyst: (a)  $C_3N_4$ , (b)  $C-N-MoS_2/CC-550$ ,  $C-N-MoS_2/CC-600$ ,  $C-N-MoS_2/CC-650$  and  $C-N-MoS_2/CC-800$ .

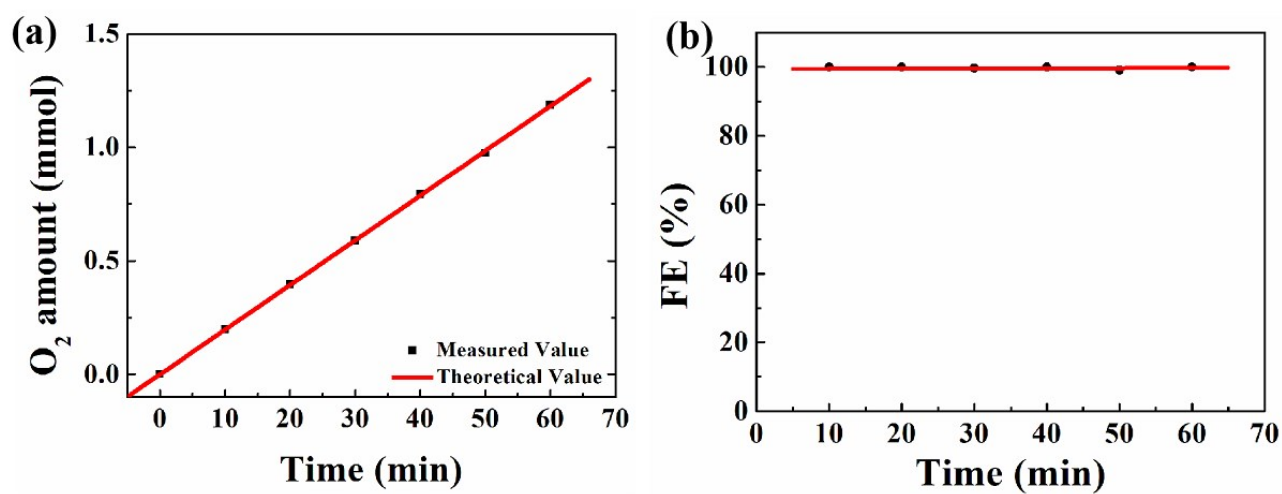


**Fig. S7.** (a), (b) and (c) The SEM image of the C-N-MoS<sub>2</sub>/CC-650, (d) The TEM image of the C-N-MoS<sub>2</sub>/CC-650.

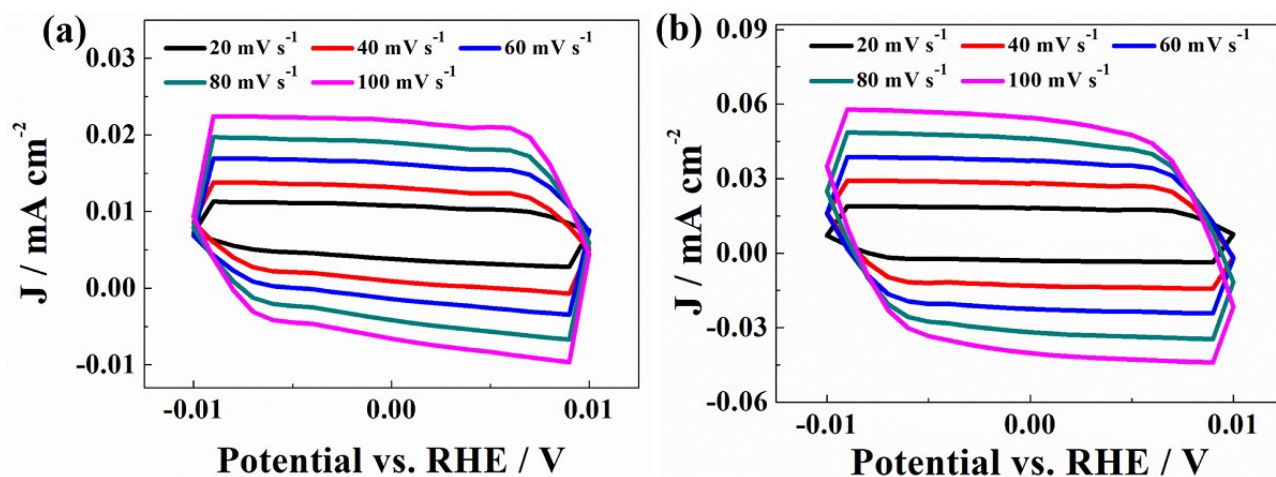




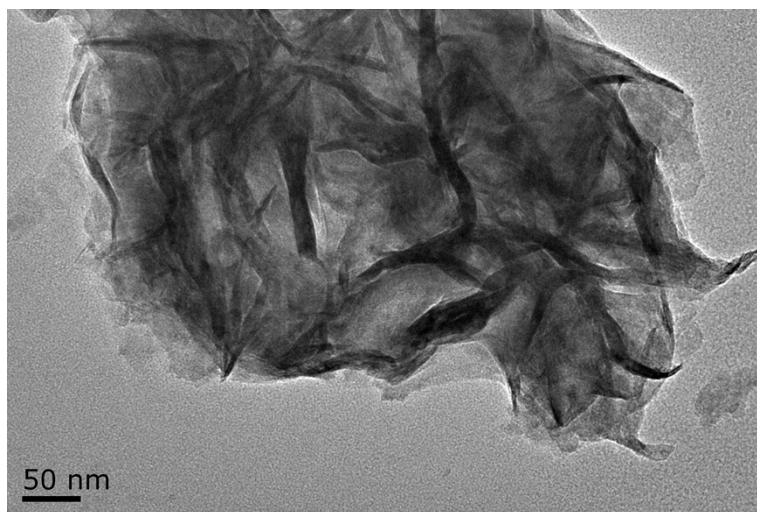
**Fig. S8.** (a), (b) and (c) The SEM image of the C-N-MoS<sub>2</sub>/CC-800, (d) The TEM image of the C-N-MoS<sub>2</sub>/CC-800.



**Fig. S9.** (a) The O<sub>2</sub> amount of C-N-MoS<sub>2</sub>/CC-700 generated at a current density of 10 mA cm<sup>-2</sup> and (b) corresponding Faraday efficiency.



**Fig. S10.** CV curves at various scan rates in the potential range -0.01~0.01 V vs. RHE for (a) MoS<sub>2</sub>/CC, (b) C-N-MoS<sub>2</sub>/CC-700, respectively.



**Fig. S11.** The TEM image of the C-N-MoS<sub>2</sub>/CC-700 after OER.

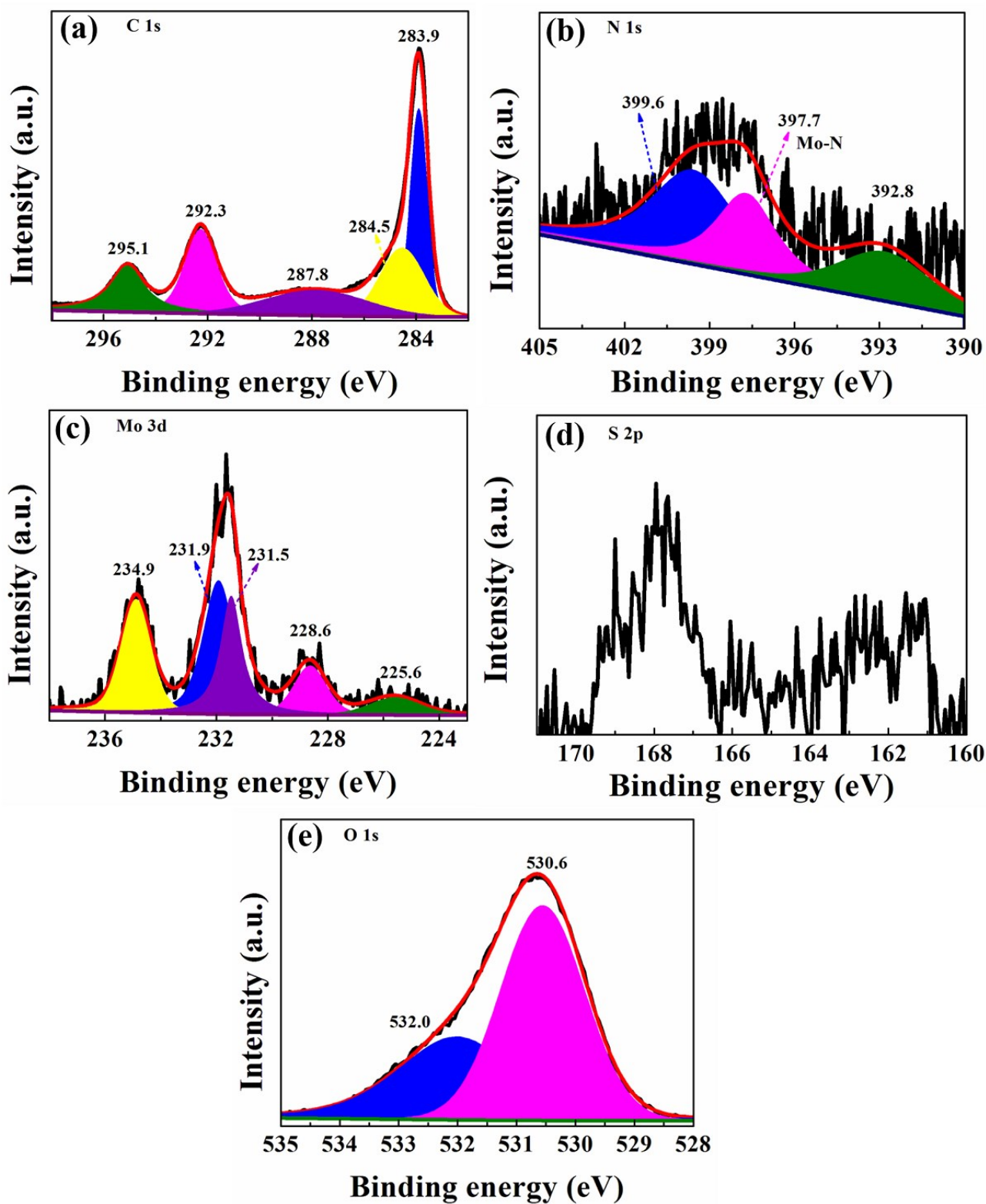
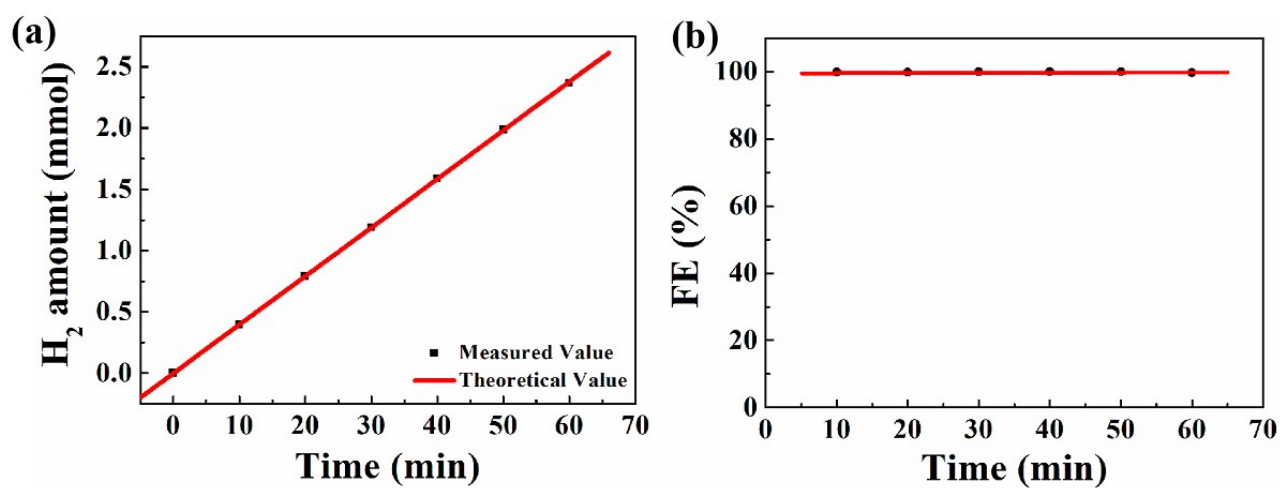
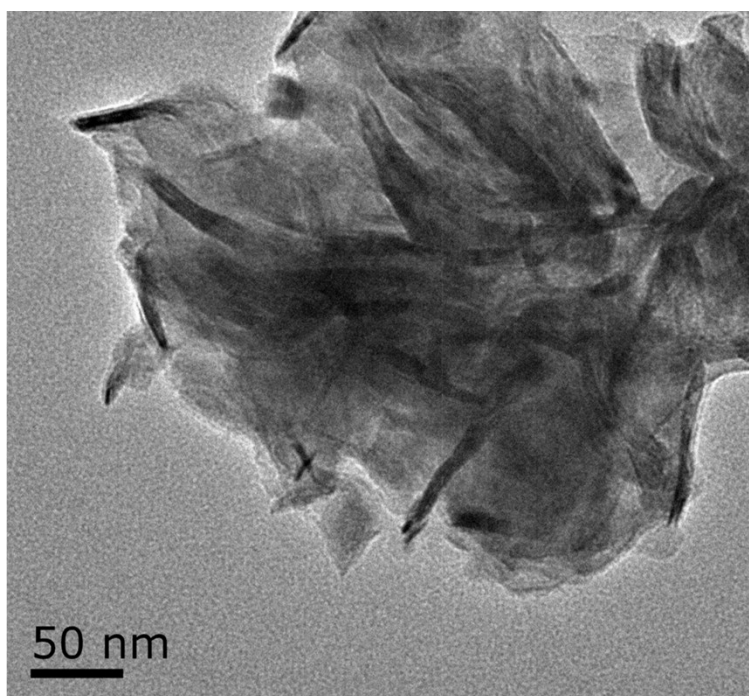


Fig. S12. The XPS spectra of the C-N-MoS<sub>2</sub>/CC-700 after OER.



**Fig. S13.** (a) The H<sub>2</sub> amount of C-N-MoS<sub>2</sub>/CC-700 generated at a current density of 10 mA cm<sup>-2</sup> and (b) corresponding Faraday efficiency.



**Fig. S14.** The TEM image of the C-N-MoS<sub>2</sub>/CC-700 after HER.

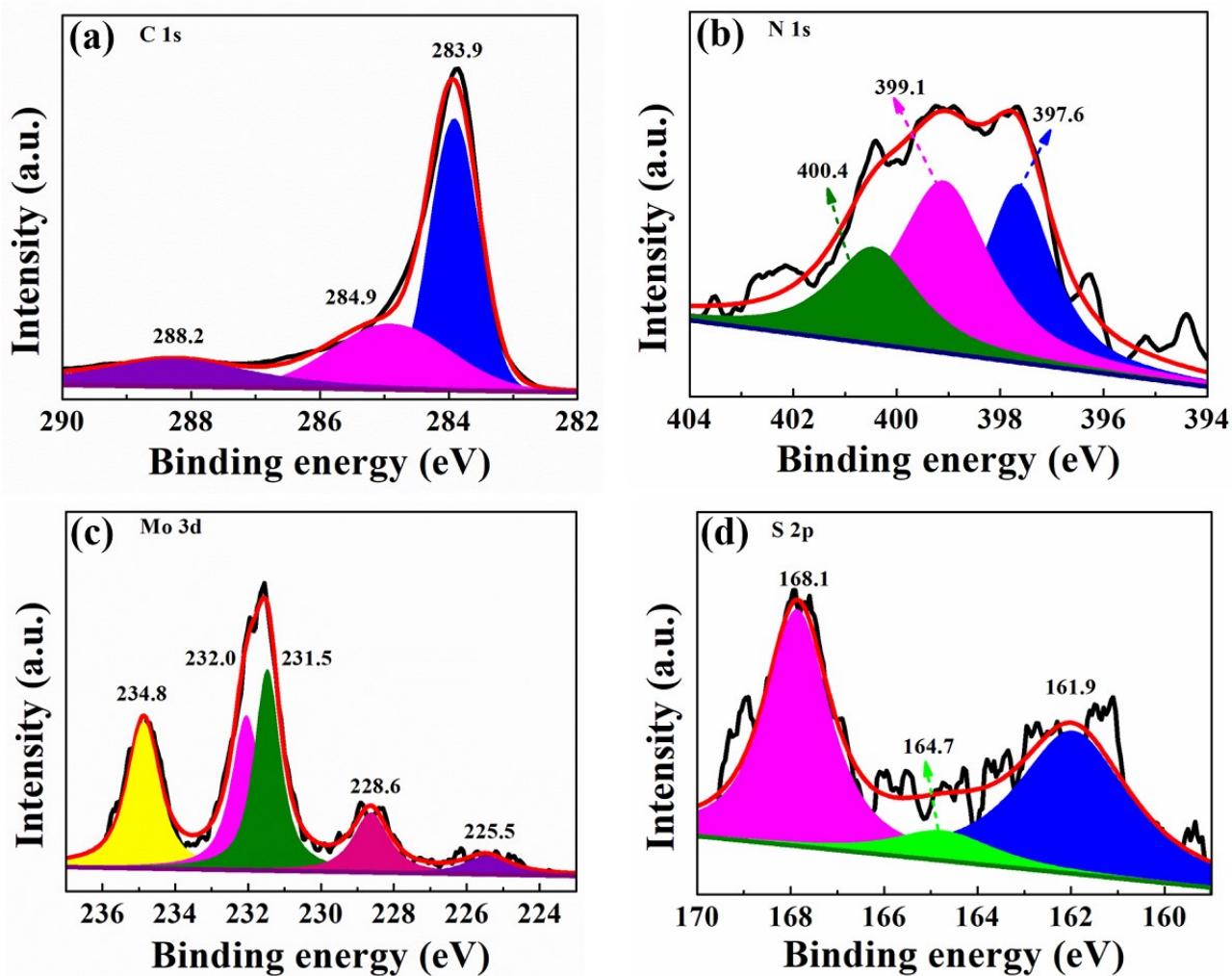
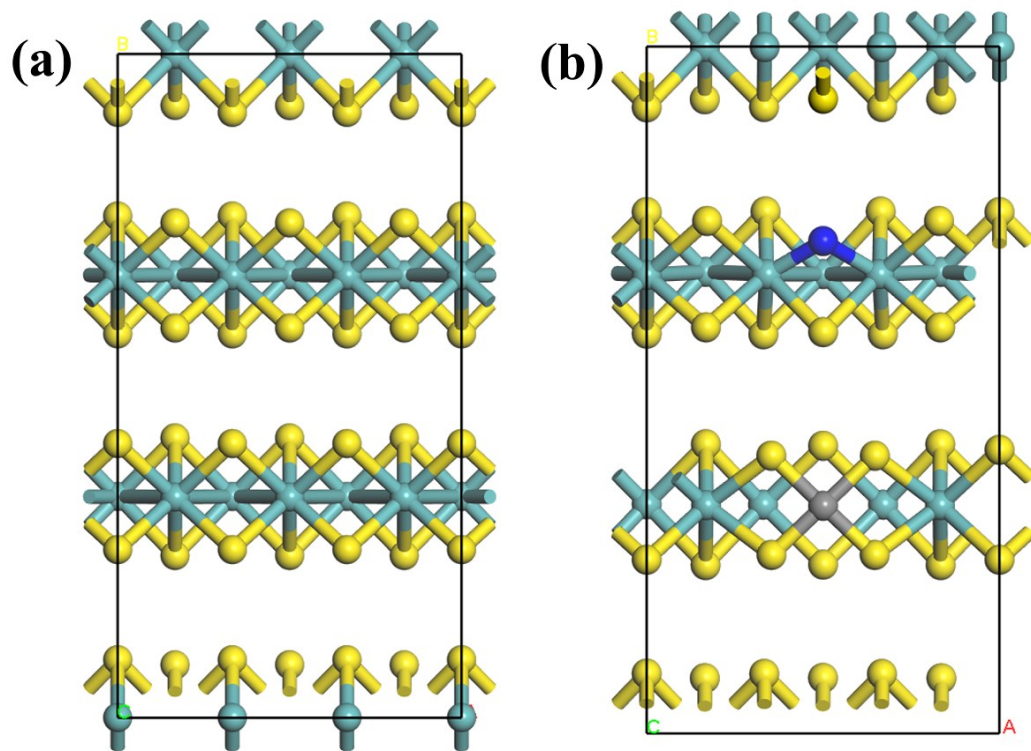
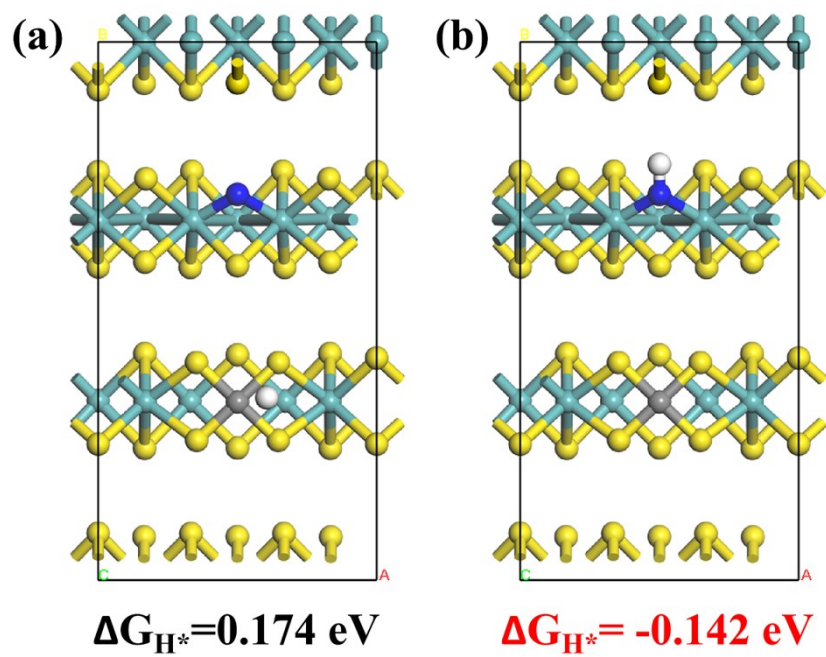


Fig. S15. The XPS spectra of the C-N-MoS<sub>2</sub>/CC-700 after HER.

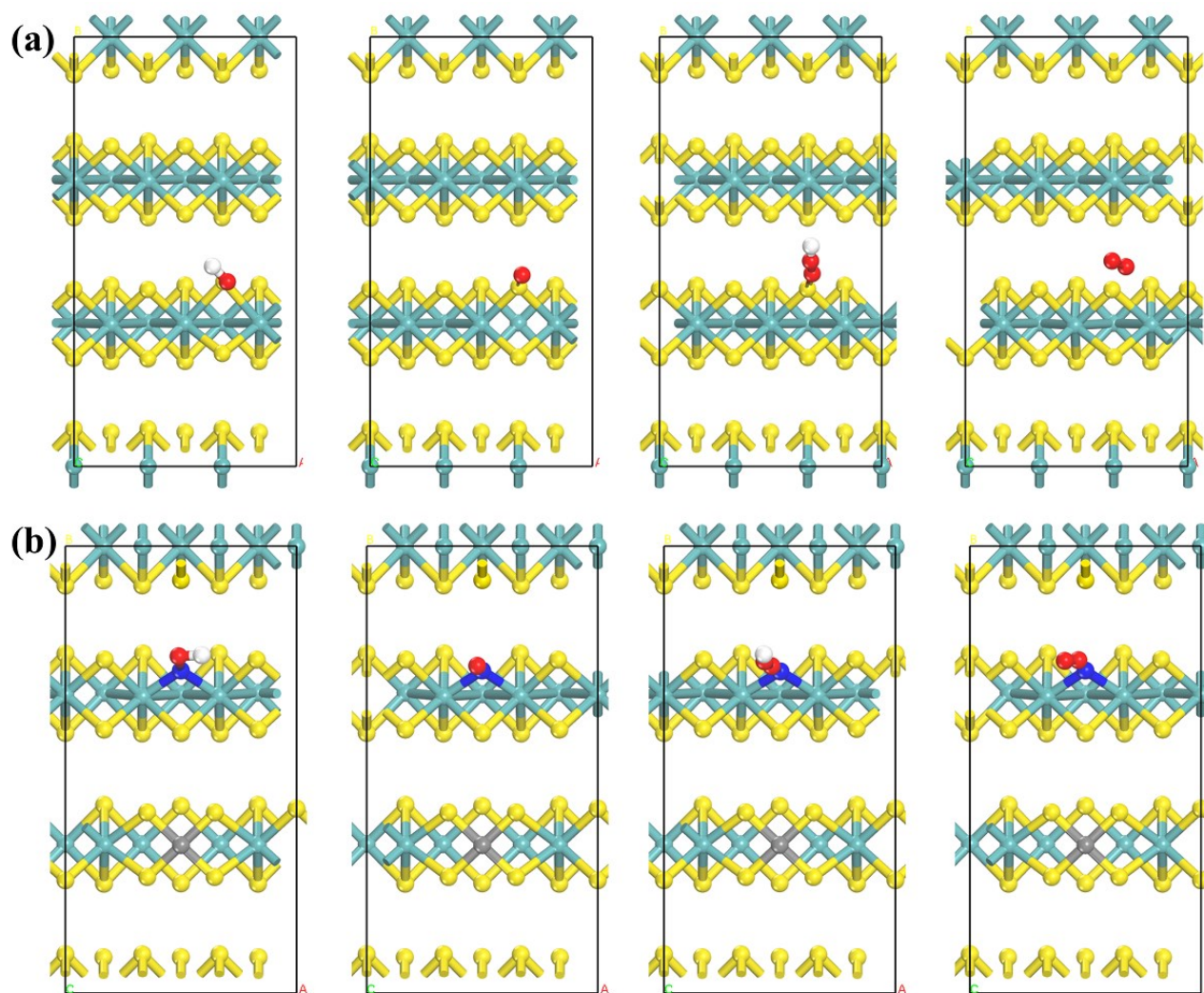




**Fig. S16.** The optimized atomic structure model for (a) MoS<sub>2</sub> and (b) C-N-MoS<sub>2</sub>-700.



**Fig. S17.** The influence of different adsorption active sites.



**Fig. S18.** The intermediates configuration of OER for (a) pure MoS<sub>2</sub> and (b) C-N-MoS<sub>2</sub>-700.

Table S1 The atomic ratio of the prepared catalyst analyzed by XPS.

Sample	Atomic concentration (%)				Atomic ratio
	C	N	Mo	S	C/N
<b>C-N-MoS<sub>2</sub>/CC-550</b>	53.77	38.67	3.14	4.42	1.4
<b>C-N-MoS<sub>2</sub>/CC-600</b>	62.71	30.29	3.02	3.98	2.1
<b>C-N-MoS<sub>2</sub>/CC-650</b>	67.32	25.80	2.99	3.89	2.6
<b>C-N-MoS<sub>2</sub>/CC-700</b>	74.39	18.98	2.87	3.76	3.9
<b>C-N-MoS<sub>2</sub>/CC-800</b>	77.14	16.17	2.90	3.79	4.8

**Table S2** The comparison of OER performance with state-of-the-art electrocatalysts.

Materials	Supports	Electrolytes	$\eta_{J=10 \text{ mA cm}^{-2}}$ (mV)	References
CN-MoS <sub>2</sub> /CC-700	CC	1 M KOH	230	This work
MoS <sub>2</sub> /NiS	GC	1 M KOH	350	1
CoNC@MoS <sub>2</sub> /CNF	GC	1 M KOH	325	2
Co(OH) <sub>2</sub> @aMoS <sub>2+x</sub>	-	1 M KOH	380	3
Co <sub>9</sub> S <sub>8</sub> @MoS <sub>2</sub> /CNFs	-	1 M KOH	430	4
MoS <sub>2</sub> -Ni <sub>3</sub> S <sub>2</sub> HNRs	NF	1 M KOH	249	5

**Table S3** TOF of the as-prepared catalysts at overpotential of 200, 250 and 300 mV corresponding to OER.

<b>TOF s<sup>-1</sup>(mV)</b> <b>Samples</b>	<b><math>\eta=200</math></b>	<b>250</b>	<b>300</b>
<b>MoS<sub>2</sub>/CC</b>	0.00843	0.0120	0.0150
<b>C-N-MoS<sub>2</sub>/CC-550</b>	0.0201	0.0294	0.0375
<b>C-N-MoS<sub>2</sub>/CC-600</b>	0.0326	0.0494	0.0821
<b>C-N-MoS<sub>2</sub>/CC-650</b>	0.0471	0.0657	0.1050
<b>C-N-MoS<sub>2</sub>/CC-700</b>	0.0827	0.1260	0.1530
<b>C-N-MoS<sub>2</sub>/CC-800</b>	0.0122	0.0150	0.0179

**Table S4** The comparison of HER performance with state-of-the-art electrocatalysts.

Materials	Supports	Electrolytes	$\eta_{J=10 \text{ mA cm}^{-2}}$ (mV)	References
C-N-MoS <sub>2</sub> /CC-700	CC	1 M KOH	90	This work
MoS <sub>2+x</sub> nanoparticles	-	1M KOH	310	1
CoNC@MoS <sub>2</sub> /CNF	CC	1M KOH	143	2
MoS <sub>2</sub> /NiCoS	GC	1 M KOH	189	6
MoS <sub>2</sub> /NiS	GC	1 M KOH	244	7
CoS <sub>x</sub> @MoS <sub>2</sub>	Ni foil	1 M KOH	146	8
MoS <sub>2</sub> @CoO	CC	1 M KOH	325	9
NiS <sub>2</sub> /MoS <sub>2</sub>	GC	1 M KOH	204	10
OGNs@MoS <sub>2</sub> -40	-	1M KOH	125	11

**Table S5** TOF of the as-prepared catalysts at overpotential of 200, 250 and 300 mV corresponding to HER.

<b>TOF s<sup>-1</sup>(mV)</b> <b>Samples</b>	<b><math>\eta=200</math></b>	<b>250</b>	<b>300</b>
<b>MoS<sub>2</sub>/CC</b>	0.00985	0.0190	0.0250
<b>C-N-MoS<sub>2</sub>/CC-550</b>	0.0269	0.0334	0.0415
<b>C-N-MoS<sub>2</sub>/CC-600</b>	0.0386	0.0586	0.0861
<b>C-N-MoS<sub>2</sub>/CC-650</b>	0.0651	0.0889	0.1190
<b>C-N-MoS<sub>2</sub>/CC-700</b>	0.1130	0.1470	0.1860
<b>C-N-MoS<sub>2</sub>/CC-800</b>	0.0181	0.0223	0.0272



## References

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